

COMPLEX FLOW OF NANOCONFINED POLYMERS

Connie B. Roth, Chris A. Murray and
John R. Dutcher

Department of Physics
University of Guelph
Guelph, Ontario, Canada
N1G 2W1



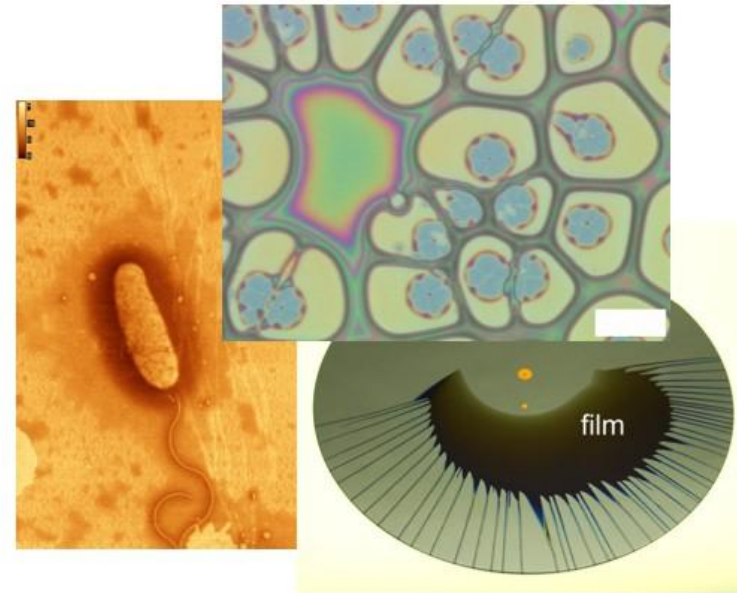
OUTLINE

- instabilities in freely-standing liquid films
- hole growth in freely-standing PS films
 - ideal geometry for probing complex flow
 - shear thinning
 - convective constraint release relaxation mechanism
 - hole growth occurs for T comparable to T_g^{bulk}
- hole growth in freely-standing PS/PI/PS trilayer films
 - holes in central PI layer
- summary & conclusions

CURRENT PROJECTS

POLYMERS

- molecular mobility
 - glass transition & hole growth
- instabilities & pattern formation
- biodegradable polymers

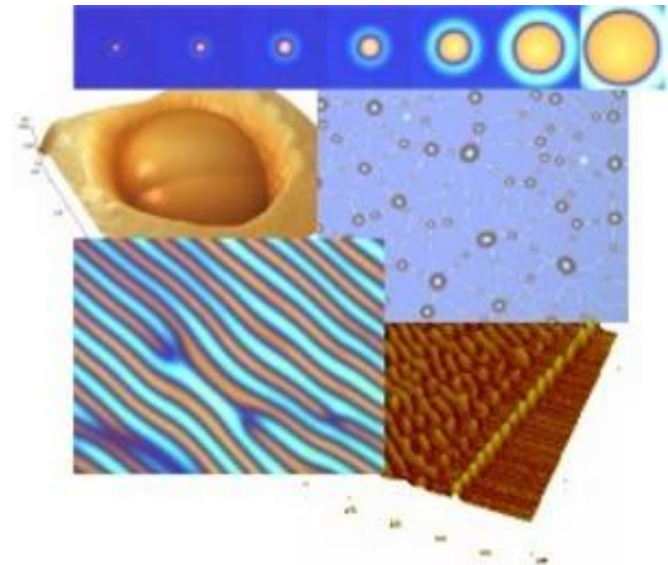


BIOPOLYMERS

- polypeptides & proteins – lipid membranes & polymer brushes

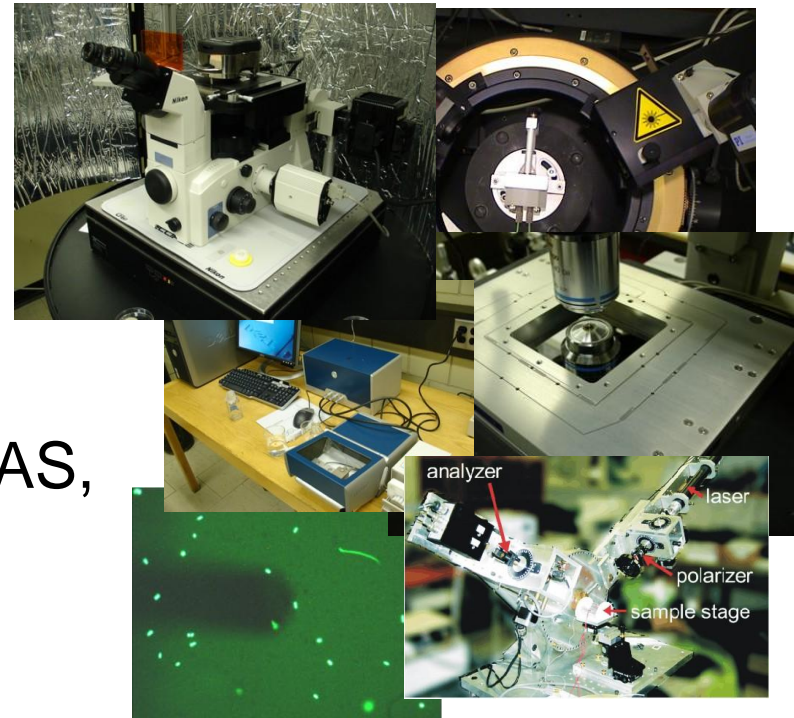
BACTERIAL CELLS

- bacterial adhesion & physical properties of bacteria & biofilms



SURFACE-SENSITIVE PROBES

- to measure structure, dynamics, interaction forces, molecular conformations, adsorption kinetics, we use
 - atomic force microscopy
 - ellipsometry
 - surface plasmon resonance
 - quartz crystal microbalance
 - optical tweezers
 - TIRF
 - infrared techniques (PM-IRRAS, ATR-FTIR)
 - surface circular dichroism
 - TEM
 - differential pressure techniques

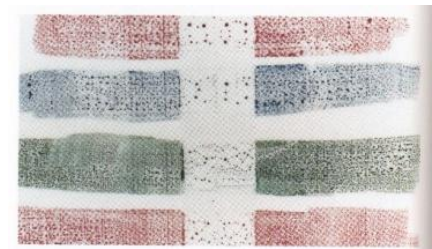
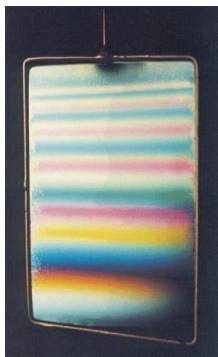


THIN LIQUID FILMS

- thin liquid films occur in everyday life
 - adhesives (superglue)
 - lubricants (on cornea of eye, engine piston)
 - spray coatings (paint, herbicides, fibers)
 - printing (ink on transparency or tape)
 - soap bubbles & films
 - foams (shaving cream, cappuccino)
 - water films (water spotting, hydroplaning)

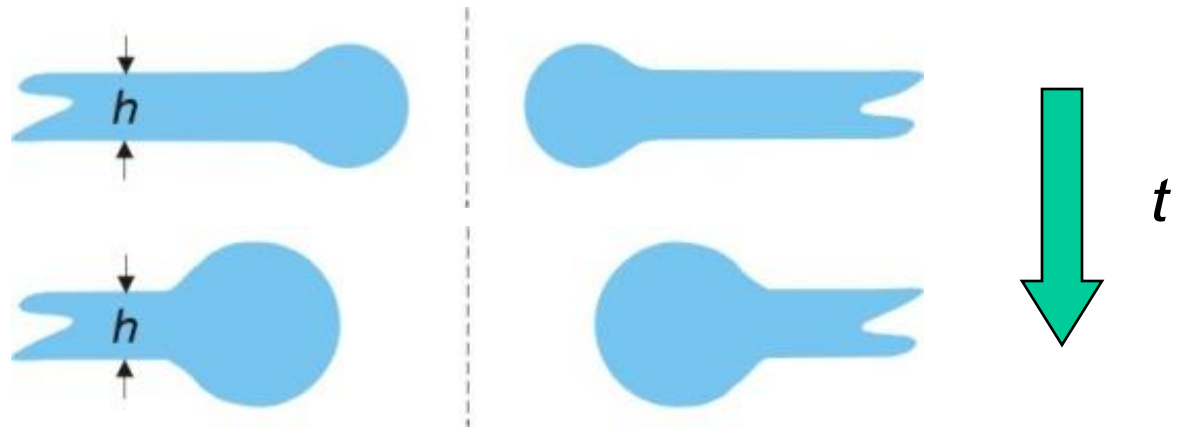
stability
desirable/
essential

stability
undesirable

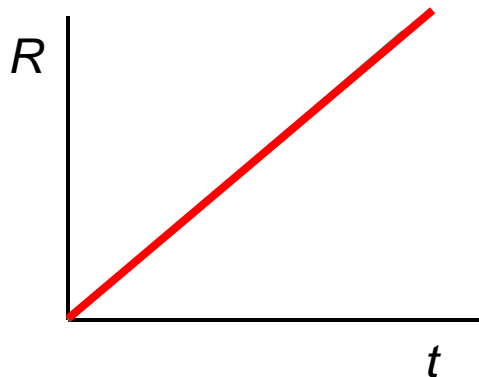


HOLE GROWTH IN NON-VISCOUS FILMS

- fluid collects in a rim
- rest of film undisturbed



- hole radius grows linearly with time

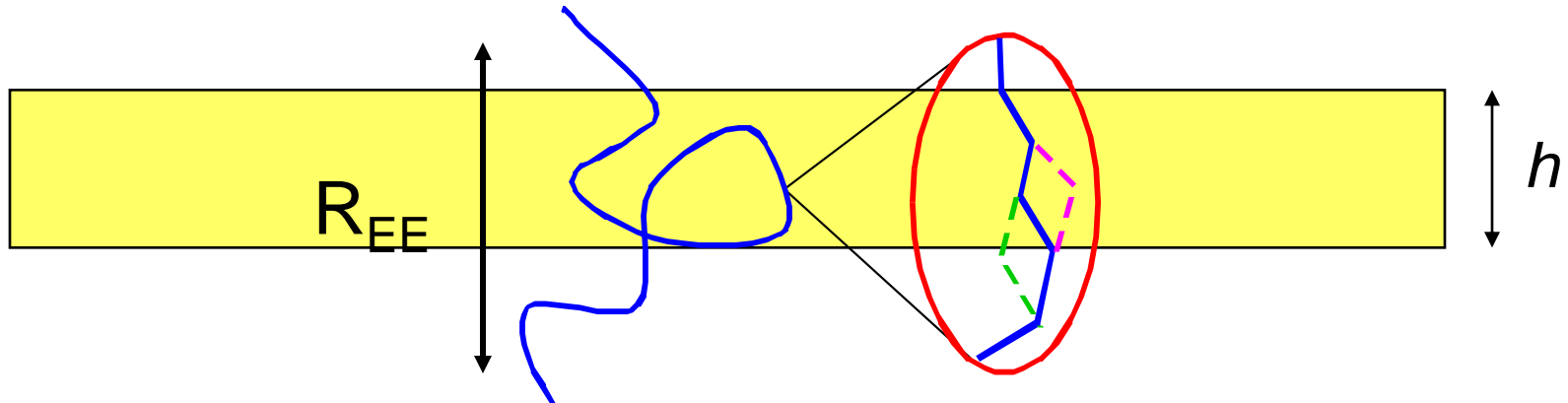


[Taylor, Proc. Roy. Soc. (1959)]

[Culick, J. Appl. Phys. (1960)]

POLYMER MOLECULES

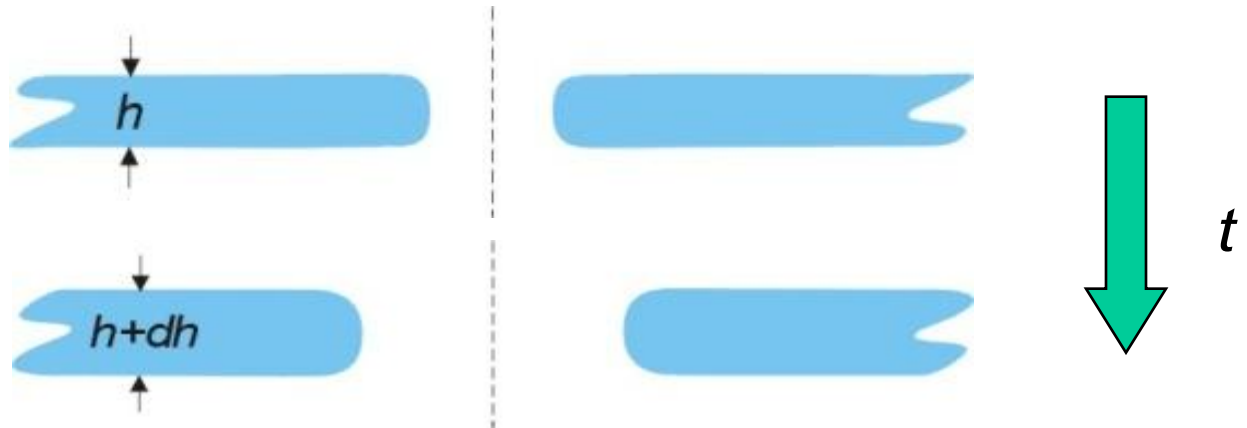
- polymers are complex molecules
 - different length scales ranging from segment size to overall chain size $R_{EE} \sim M_w^{0.5}$
 - different time scales ranging from segmental relaxation to diffusion of entire molecules



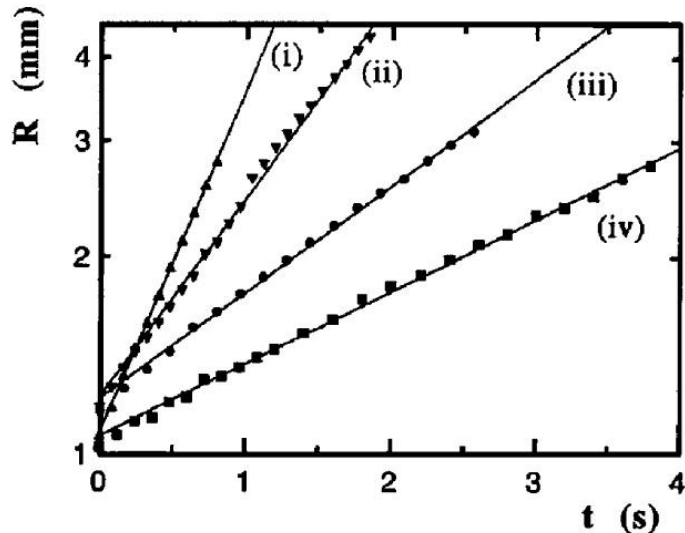
- effect of confinement in thin films
 - changes in conformation & dynamics

HOLE GROWTH IN VISCOUS FILMS

- no rim
- film thickens uniformly



- hole radius grows exponentially with time



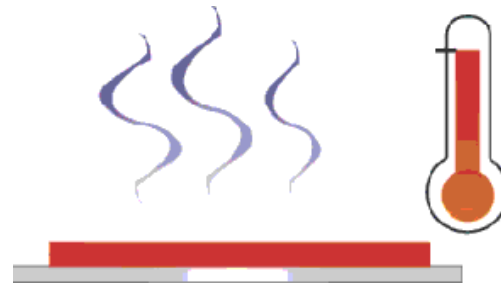
[Debrégeas *et al.*, PRL (1995)]

FREELY-STANDING FILM PREPARATION

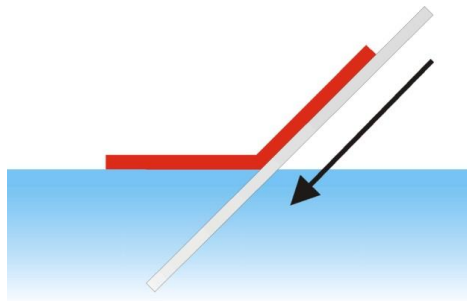
- high molecular weight, monodisperse polymers dissolved in good solvents



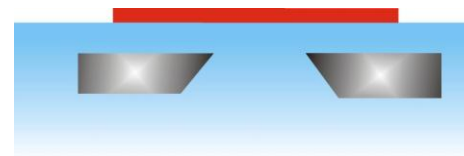
spincoat polymer solution onto mica substrate



anneal film under vacuum



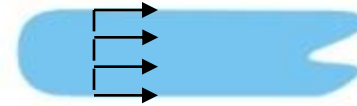
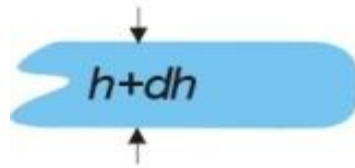
transfer film onto water surface



capture film on holder containing 4 mm diameter hole

HOLE GROWTH IN POLYMER FILMS

– plug flow

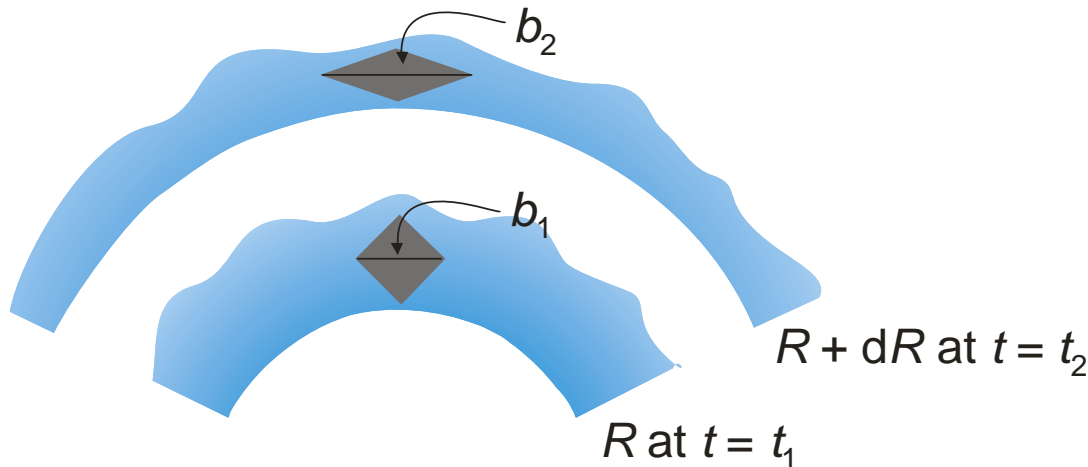


– driven by surface tension

$$\sigma = \frac{2\varepsilon}{h} \text{ at edge of hole;}$$

$$\sigma \sim \frac{1}{r^2} \text{ into rest of film}$$

– polymer chains become aligned near edge of hole

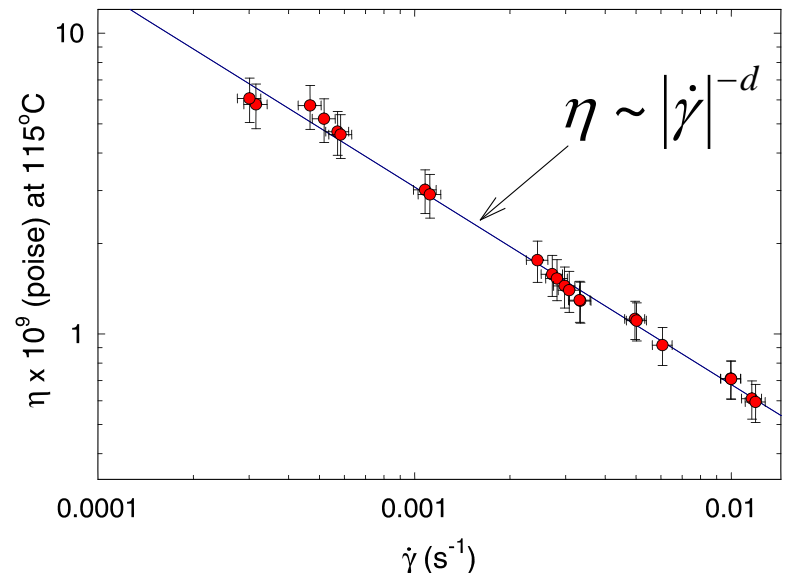
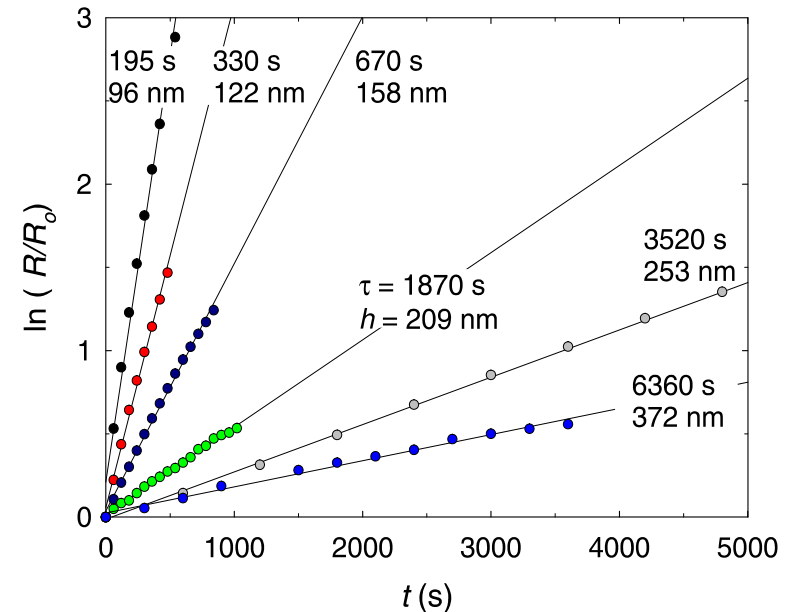


10 μm

PREVIOUS HOLE GROWTH IN PS FILMS

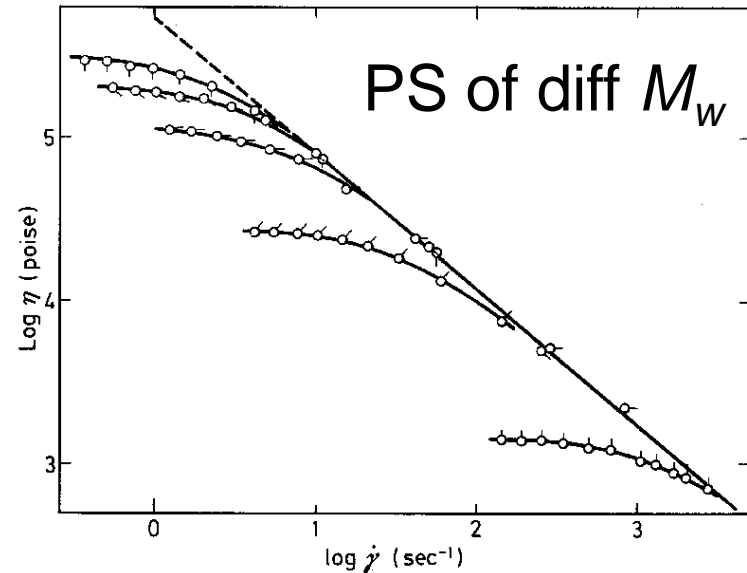
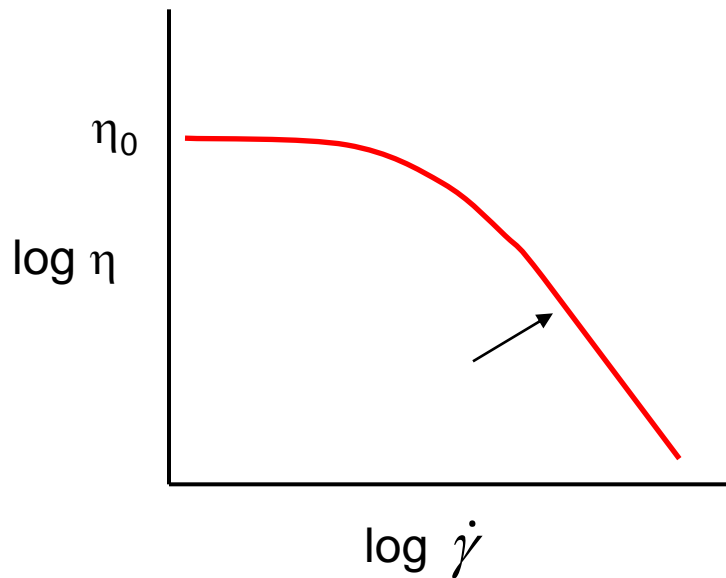
- optical microscopy of freely-standing polystyrene films
 - $M_w = 717k$
 - $96 \text{ nm} < h < 372 \text{ nm}$
 - $T = 115^\circ\text{C}$ ($T_g^{\text{bulk}} = 97^\circ\text{C}$)
 - exponential hole growth

- decrease in viscosity for increasing strain rate
- consistent with shear thinning



SHEAR THINNING OF POLYMERS

- decrease in viscosity η with increasing shear strain rate $\dot{\gamma}$



- shear thinning only observed for entangled polymers
[Peterlin, Adv. Macromol. Chem. **1**, 225 (1968)]
- η is M_w -independent in nonlinear regime
[Stratton, J. Colloid Interf. Sci. **22**, 517 (1966)]

SHEAR THINNING IN FREELY-STANDING PS FILMS

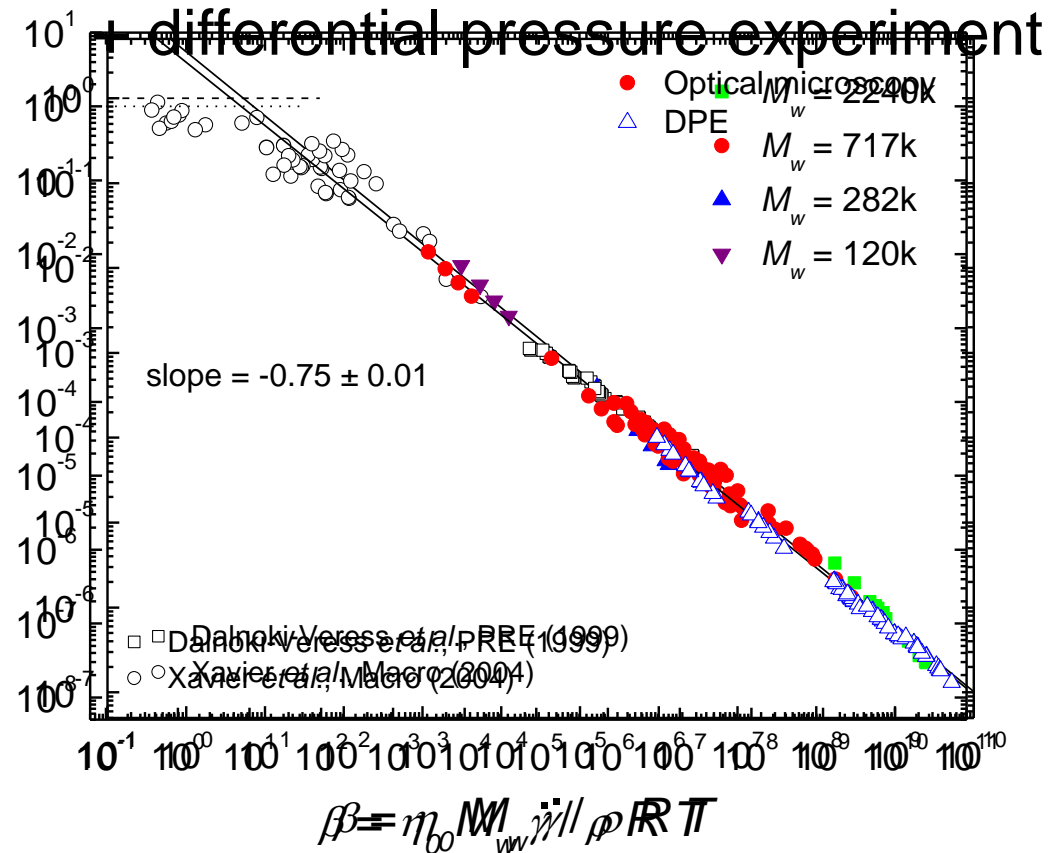
- different T , M_w and h
- use growth time τ to obtain viscosity η at edge of hole

- plot η/η_0 versus reduced shear strain rate β

$$\frac{\eta}{\eta_0}$$

- results consistent with viscous flow in presence of shear thinning

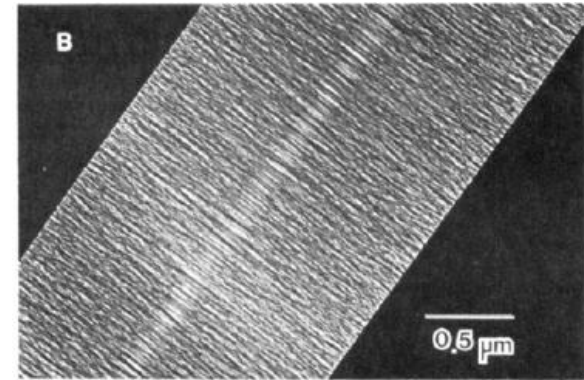
optical microscopy



[Roth & Dutcher, PRE **72**, 021803 (2005)]

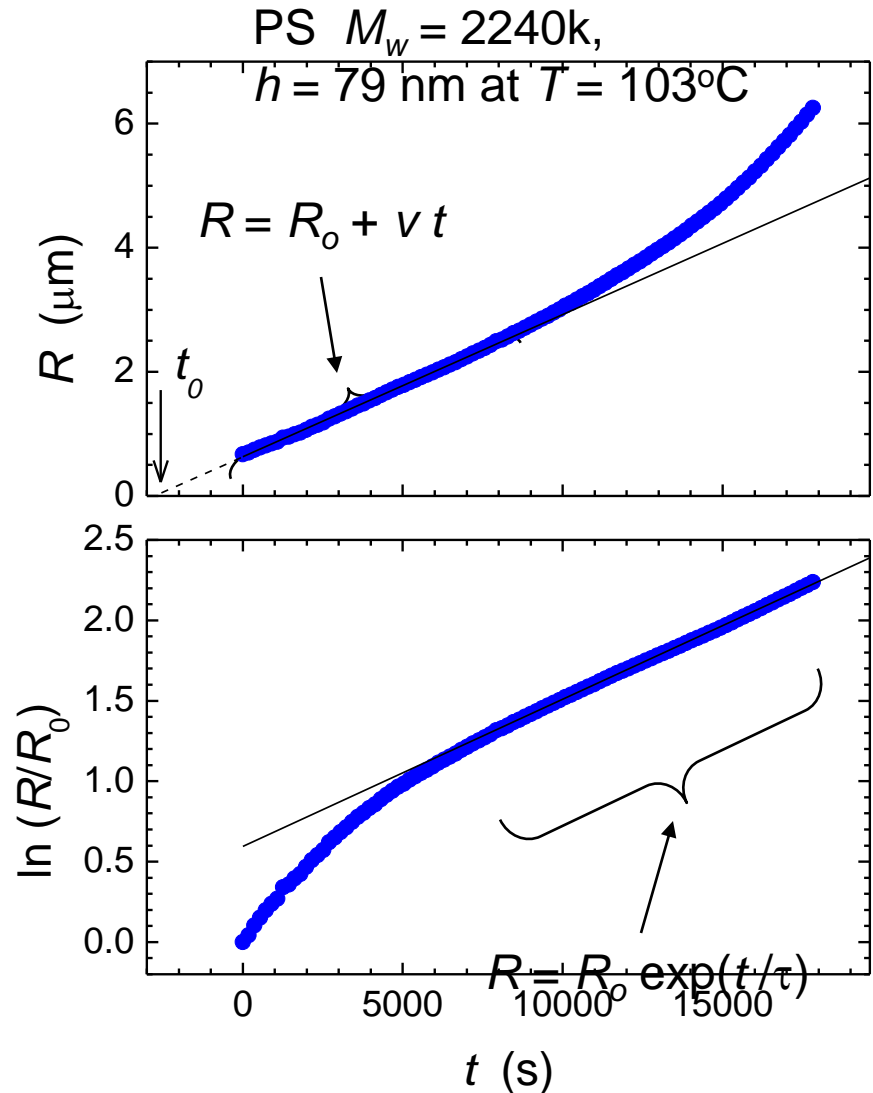
FLOW AT SUCH LOW TEMPERATURES?

- in bulk, viscosity $\eta_0 \sim 10^{12}$ Pa•s at $T \sim T_g$
 - expect both viscous and elastic effects important
 - late stage hole growth is well-described by viscous flow
- previous studies of **crazing** of PS films [Berger & Kramer, Macro (1987)]
 - **chain scission** at low temperatures
 - **chain disentanglement** at strain rates & higher temps
 - for $M_w = 1800k$: $T > 70^\circ\text{C}$ for $\dot{\gamma} = 4.1 \times 10^{-6} \text{ s}^{-1}$
 $T > 90^\circ\text{C}$ for $\dot{\gamma} \sim 10^{-2} \text{ s}^{-1}$
- comparable strain rates & temps for **hole growth**
 $1.5 \times 10^{-4} \text{ s}^{-1} < \dot{\gamma} < 2 \times 10^{-2} \text{ s}^{-1}$ for $101^\circ\text{C} < T < 117^\circ\text{C}$



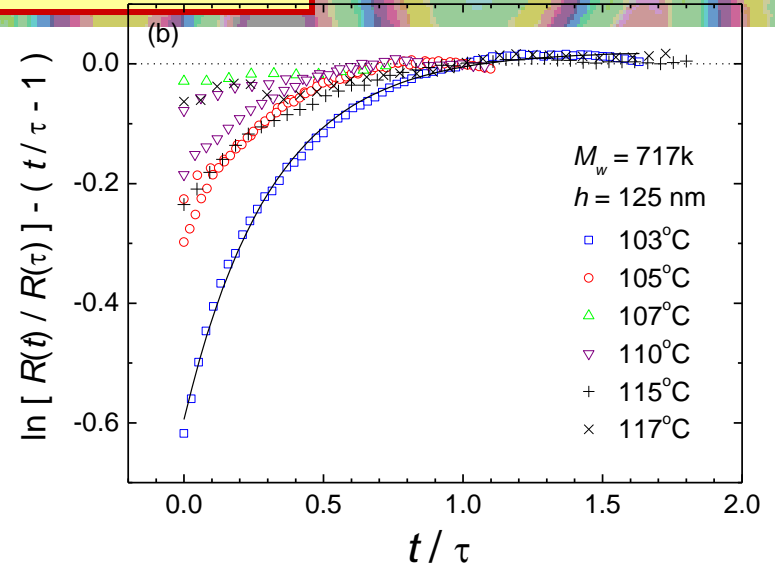
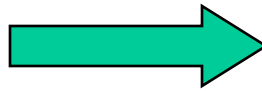
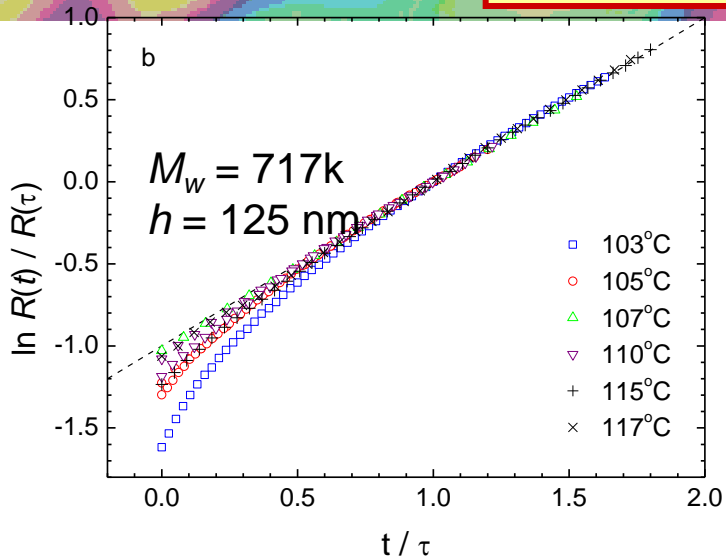
TRANSITION IN HOLE GROWTH

- measure $R(t)$ for single hole using optical microscopy
 - linear growth at early times
 - velocity v
 - exponential growth at late times
 - growth time τ
 - range of times for linear growth decreases with
 - increasing T
 - decreasing M_w



[Roth *et al.*, PRE **72**, 021802 (2005)]

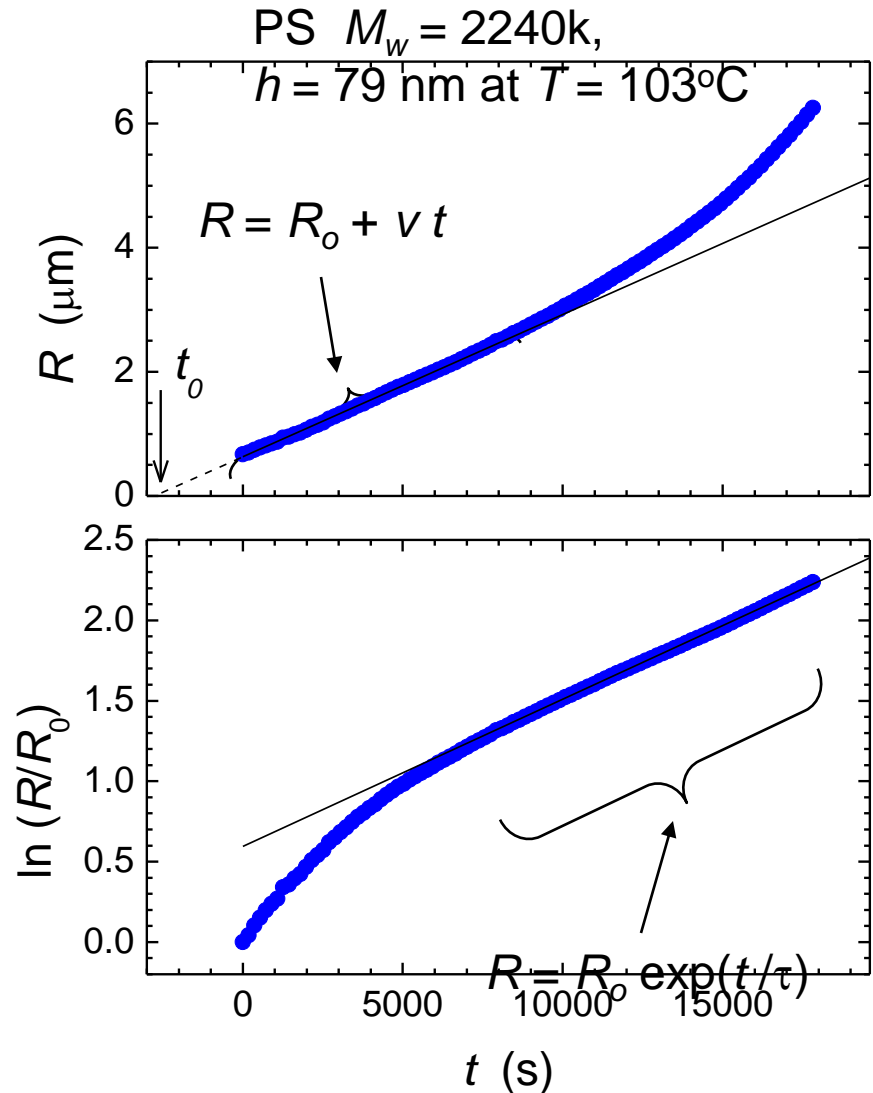
TRANSIENT BEHAVIOR



- scale axes: $\ln[R(t)/R(\tau)]$ vs t/τ
 - data sets coincide for $t > \tau$
- isolate transient
 - single exponential decay time τ_1

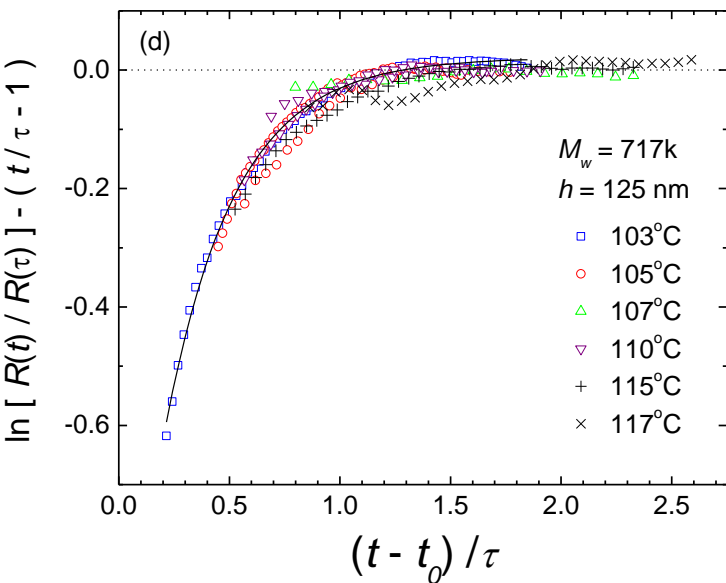
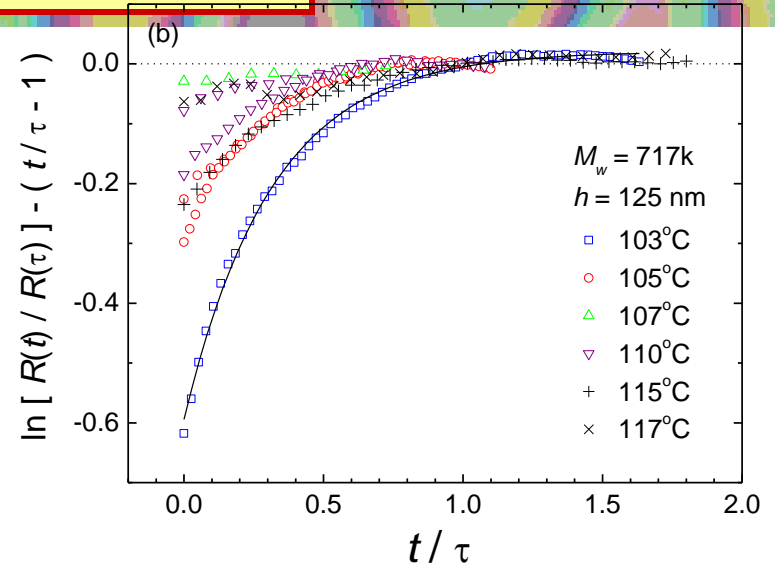
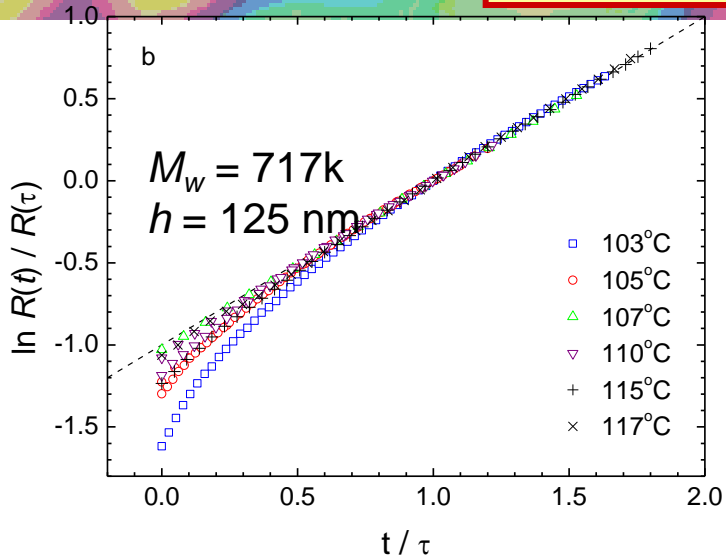
TRANSITION IN HOLE GROWTH

- measure $R(t)$ for single hole using optical microscopy
 - linear growth at early times
 - velocity v
 - exponential growth at late times
 - growth time τ
 - range of times for linear growth decreases with
 - increasing T
 - decreasing M_w



[Roth *et al.*, PRE **72**, 021802 (2005)]

TRANSIENT BEHAVIOR



- scale axes: $\ln[R(t)/R(\tau)]$ vs t/τ
 - data sets coincide for $t > \tau$
- isolate transient
 - single exponential decay time τ_1
- refer t to t_0 for which $R(t_0) = 0$
 - overlap of data
 - decay time τ_1 scales with τ

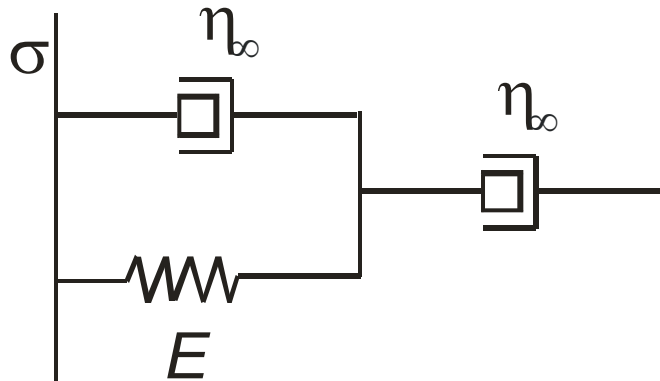
FITTING FUNCTION FOR $R(t)$

- empirically, $R(t)$ data for all times well fit by

– equivalent to time-dependent viscosity $\eta(t)$

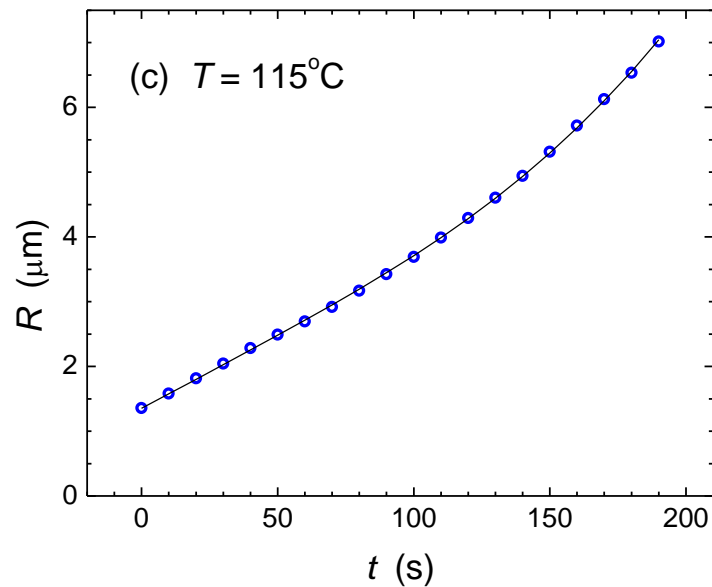
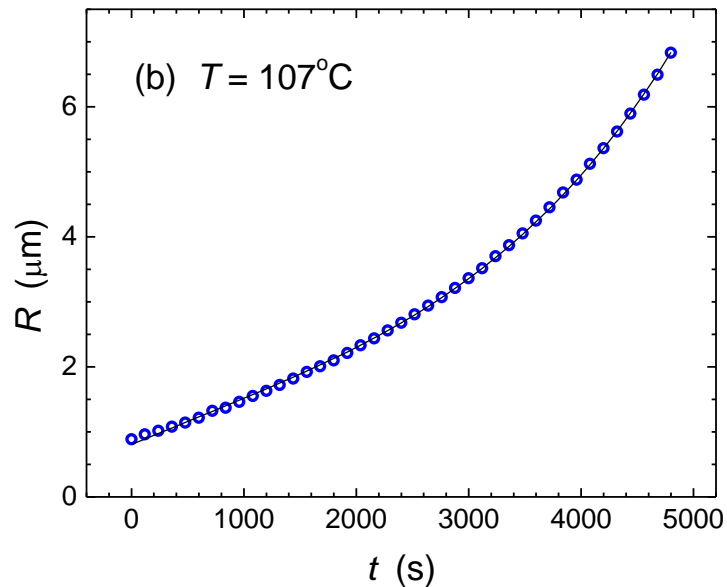
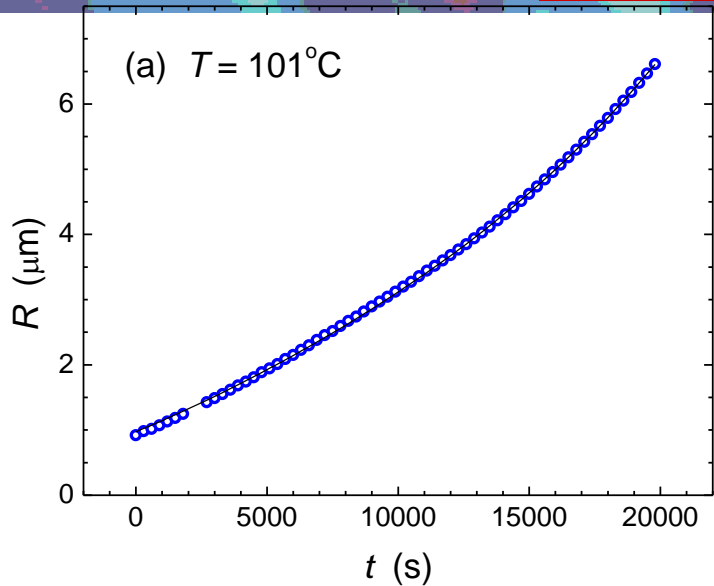
where $\eta_\infty = \frac{\varepsilon\tau}{h}$ is viscosity for $t \gg \tau_1$

– described by a three-component spring & dashpot model



single relaxation time

FITS TO $R(t)$ DATA



- 3 fitting parameters:

R_0 value at start of measurements ($t = 0$)

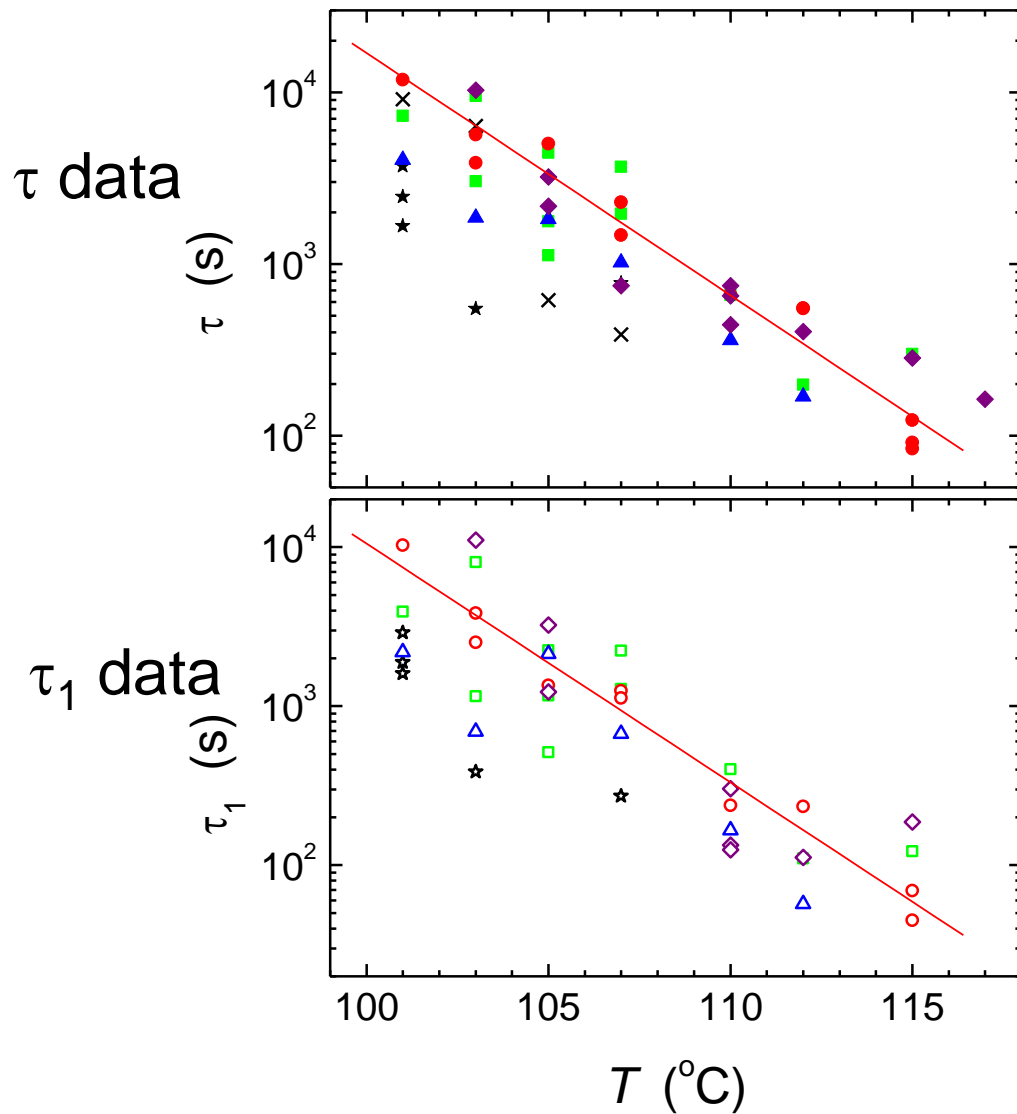
τ exponential hole growth time

τ_1 longest relaxation time

$$M_w = 717 \times 10^3$$

$$h = 90 \text{ nm}$$

RELATIONSHIP BETWEEN τ AND τ_1



• τ and τ_1 have similar temperature dependence with $\tau_1 \sim \tau/2$
 $[\tau/\tau_1 = 2.2 \pm 1.4]$

- $M_w = 2240\text{k}$, $h = 83$ nm
- ★ $M_w = 282\text{k}$, $h = 94$ nm
- × $M_w = 120\text{k}$, $h = 77$ nm
- ▲ $M_w = 717\text{k}$, $h = 61$ nm
- $M_w = 717\text{k}$, $h = 90$ nm
- ◆ $M_w = 717\text{k}$, $h = 125$ nm

TUBE MODEL FOR POLYMER DYNAMICS

low shear rate	$\dot{\gamma} < \tau_d^{-1}$	reptation + contour length fluctuations (CLF)
intermediate shear rate	$\tau_d^{-1} < \dot{\gamma} < \tau_R^{-1}$	convective constraint release (CCR)
high shear rate	$\tau_R^{-1} < \dot{\gamma}$	chain stretch

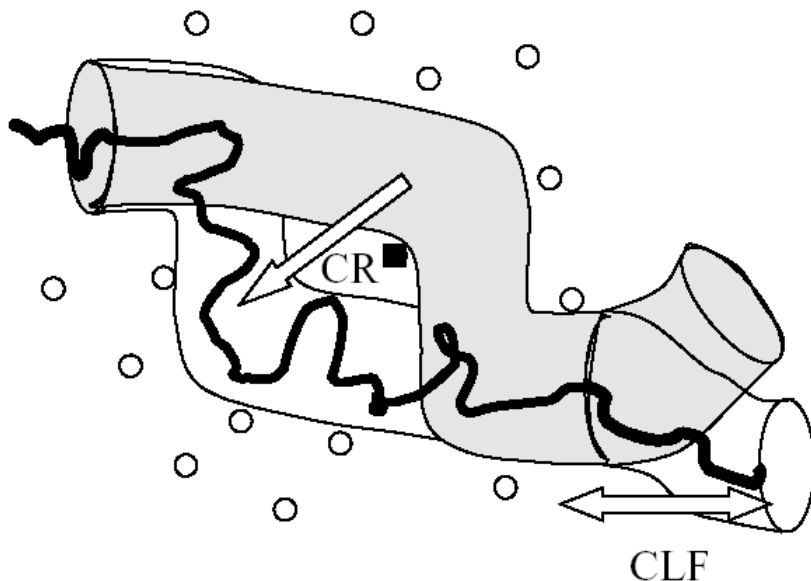
τ_d Reptation time
 τ_R Rouse time

Hole growth
 at $T = 101^\circ\text{C}$

$$\tau_d^{-1} \sim 10^{-6} - 10^{-10} \text{ s}^{-1}$$

$$\tau_R^{-1} \sim 10^{-4} - 10^{-7} \text{ s}^{-1}$$

$$\dot{\gamma} \sim 10^{-4} \text{ s}^{-1}$$



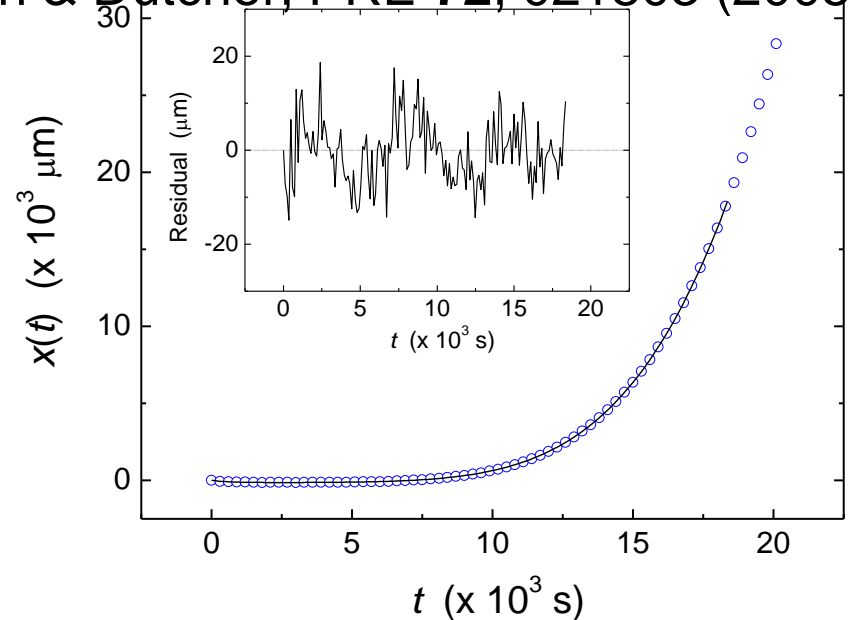
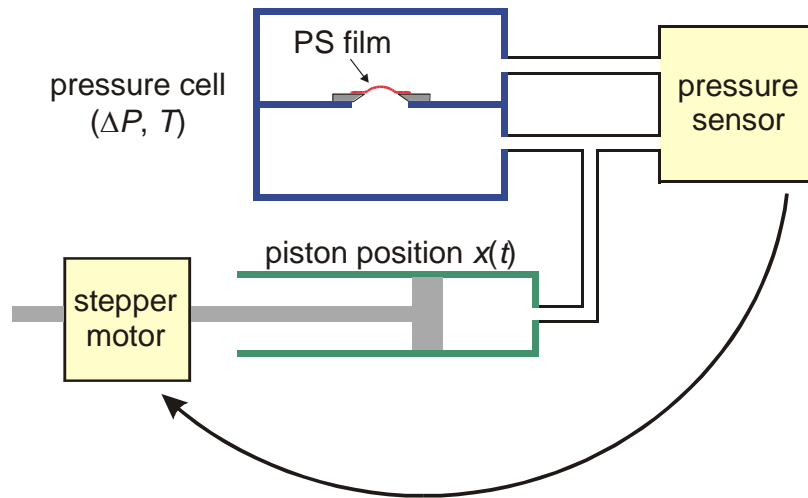
- hole growth at lowest temperatures occurs in the intermediate to high shear rate regimes
 - relaxation via CCR (no rotation in flow)
 - since $\dot{\gamma} = 2 / \tau$, expect $\tau_1 \sim \dot{\gamma}^{-1} \sim \tau / 2$
 → data consistent with CCR

[Graham, Likhtman, McLeish, and Milner, J. Rheol (2003)]

DIFFERENTIAL PRESSURE EXPERIMENT

- differential pressure experiment

[Roth *et al.*, RSI **74**, 2796 (2003); Roth & Dutcher, PRE **72**, 021803 (2005)]

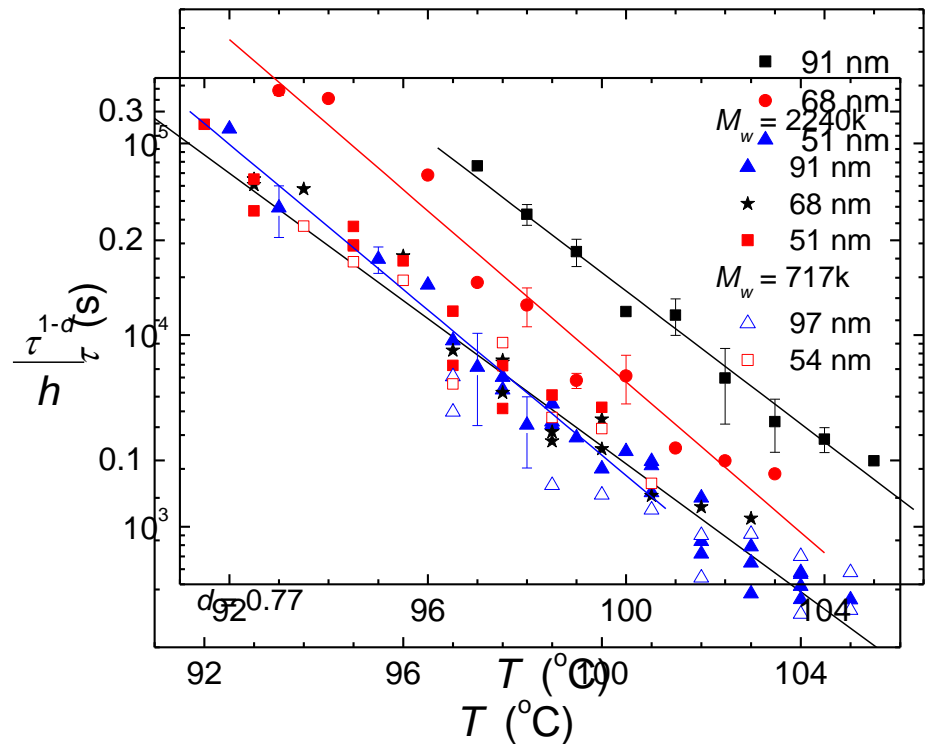


PS, $M_w = 2240\text{k}$, $h = 69 \text{ nm}$, $T = 98^\circ\text{C}$

- maintain pressure difference across PS film
- track piston position as a function of time

DPE RESULTS FOR FREELY-STANDING PS FILMS

- temperature dependence of hole growth time τ
 - $M_w = 717k, 2240k$
 - $51 \text{ nm} < h < 98 \text{ nm}$
 - $92^\circ\text{C} < T < 105^\circ\text{C}$
 - consistent with shear thinning
 - despite large differences in T_g , onset temperature for hole formation is comparable to T_g^{bulk} for all films



FREELY-STANDING TRILAYER FILMS

- trilayer films with central fluid layer and solid capping layers
 - periodic lateral morphology forms upon heating due to amplification of thermal fluctuations

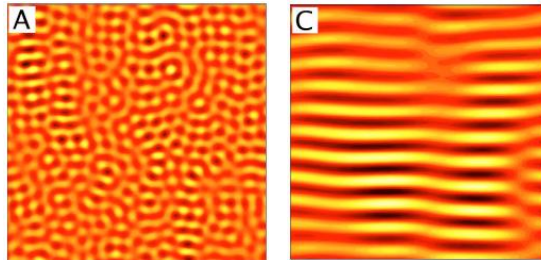
PHYSICAL REVIEW E 73, 041801 (2006)

Stress-guided self-assembly in Dutcher films

Gavin A. Buxton and Nigel Clarke

Department of Chemistry, University of Durham, Durham DH1 3LE, United Kingdom

(Received 28 November 2005; published 10 April 2006)



PAPER

www.rsc.org/softmatter | Soft Matter

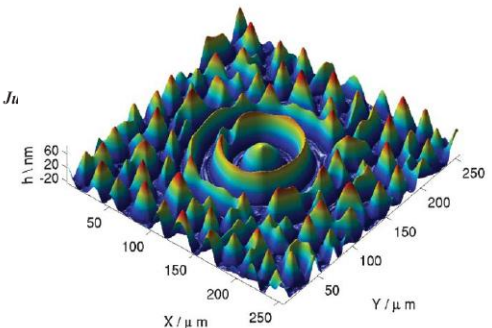
Structural evolution and control of Dutcher films

Gavin A. Buxton* and Nigel Clarke

Received 4th April 2006, Accepted 25th May 2006

First published as an Advance Article on the web 14th June 2006

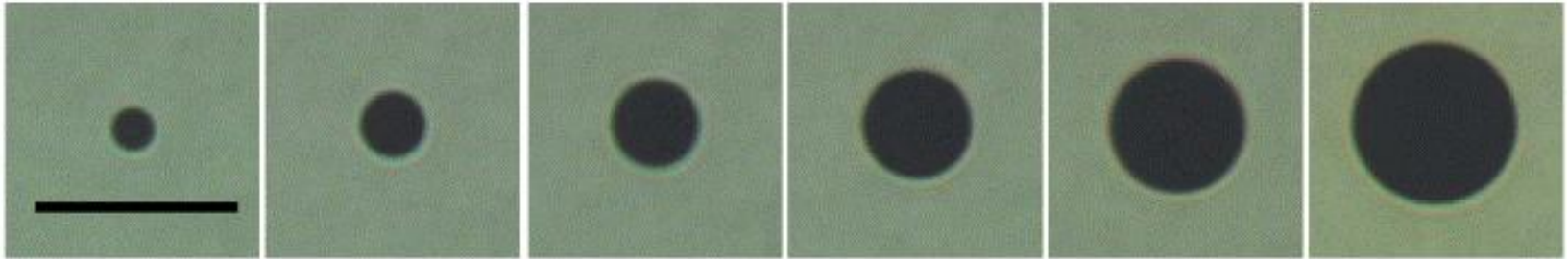
DOI: 10.1039/b604790d



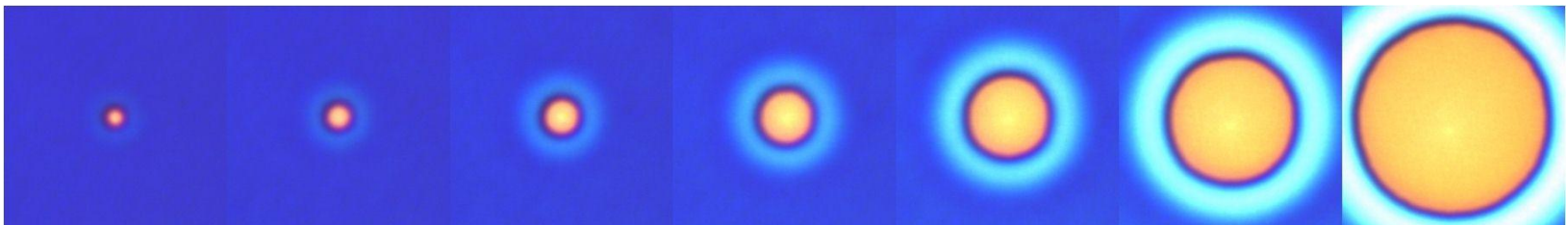
[C.A. Murray *et al.*, PRE **69**, 061612 (2004)]

HOLE GROWTH IN PS/PI/PS TRILAYERS

- hole growth in PS freely-standing films
 - uniform thickening of films
 - absence of rim at edge of hole



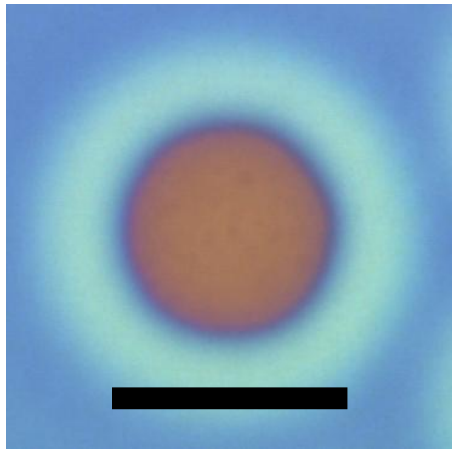
- hole growth in PS/PI/PS freely-standing films
 - holes form & grow in central PI layer
 - distinct rim at edge of hole



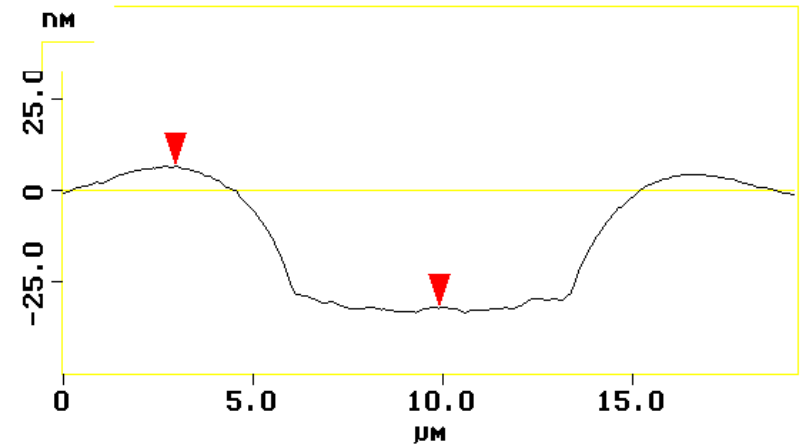
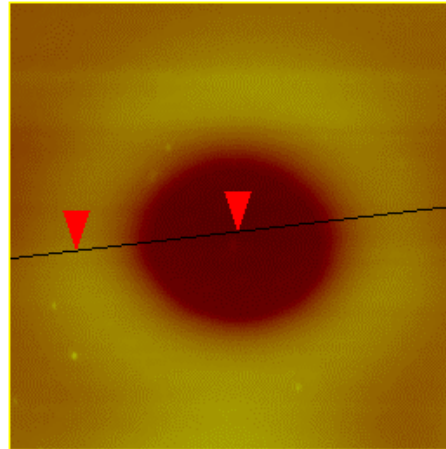
HOLE GROWTH IN PS/PI/PS TRILAYERS

- presence of rim verified using atomic force microscopy (AFM)

$h = 50 \text{ nm}$, $L = 75 \text{ nm}$



optical
microscopy

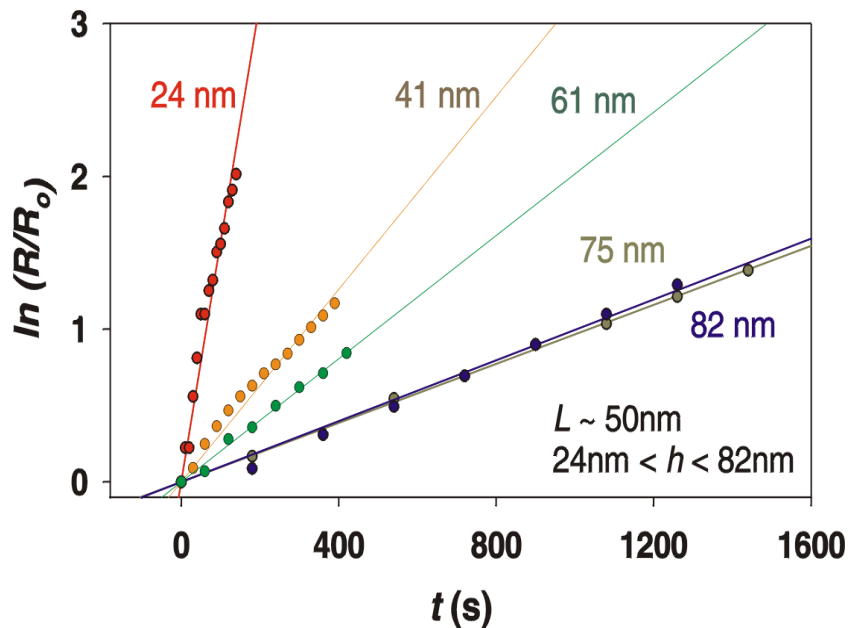


AFM

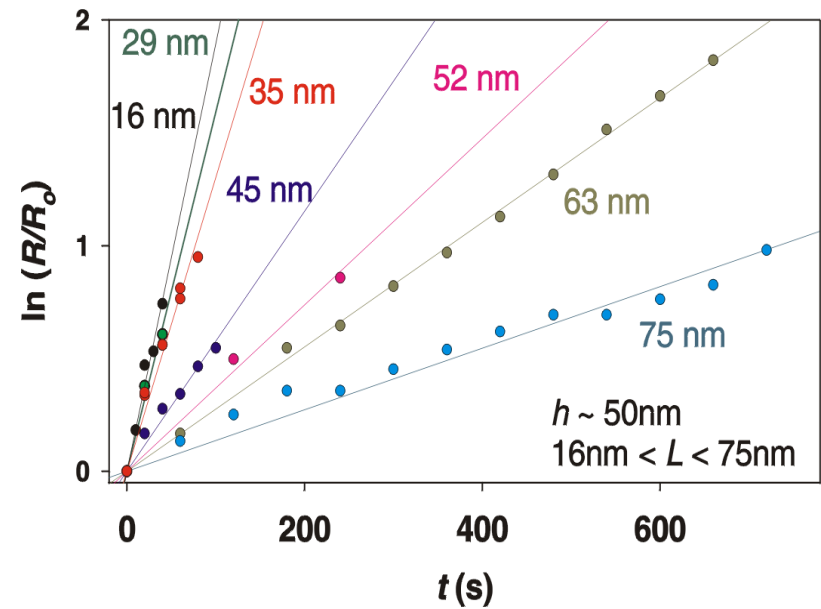
[C.A. Murray *et al.* (2006)]

HOLE GROWTH IN PS/PI/PS TRILAYERS

- radius of hole in PI layer measured at fixed temperature
 $T = 110^\circ\text{C}$



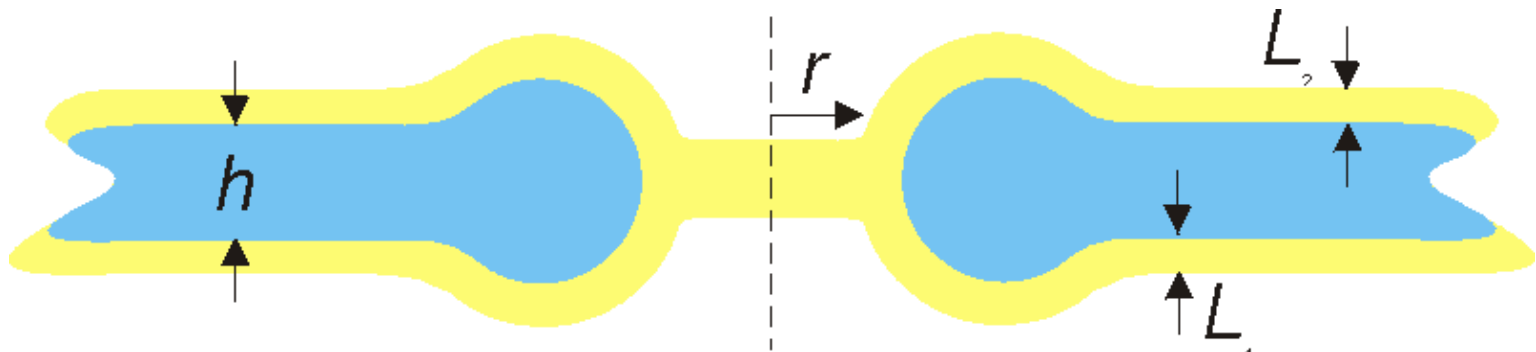
fix PS thickness L
vary PI thickness h



fix PI thickness h
vary PS thickness L

HOLE GROWTH IN PS/PI/PS TRILAYERS

- relevant factors that determine hole growth in PI layer
 - surface & PS/PI interfacial energies
 - bending energy of PS layers
 - dispersion interaction between the PS/air interfaces



- can understand slowing of hole growth with increase in h & L

SUMMARY

- hole growth in freely-standing PS films
 - two different experiments
 - shear thinning
 - convective constraint release
 - hole growth occurs at temperatures comparable to T_g^{bulk}
- hole growth in fs PS/PI/PS films
 - qualitatively different hole growth
 - hole growth in PI determined by PS

